

Pattern Gradation and Repetition with Application to High-Rise Building Design

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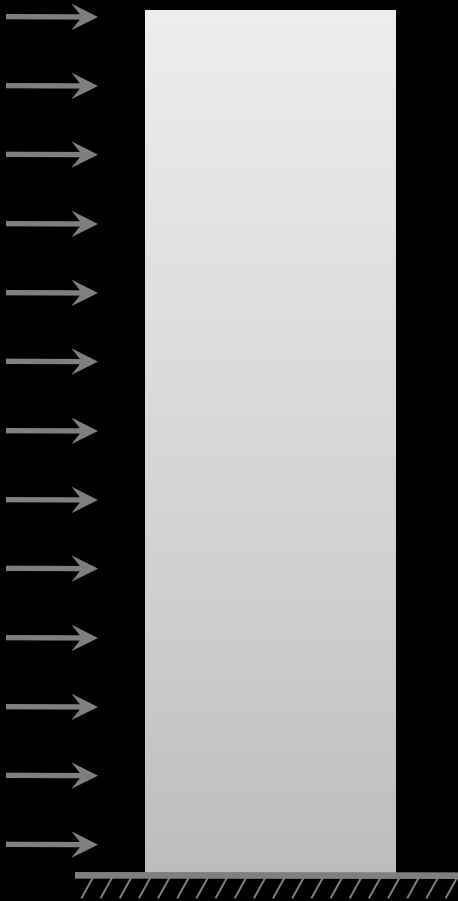
July 17th, 2009

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Skidmore, Owings & Merrill, LLP



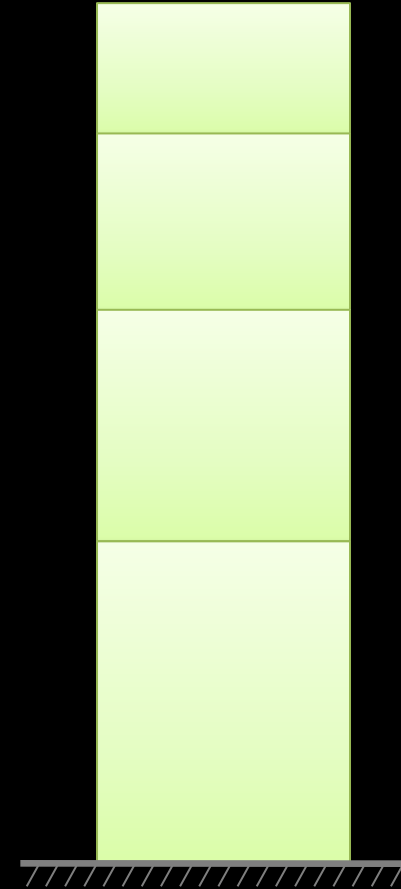
Motivation: Functionally Graded Buildings



Unconstrained Problem

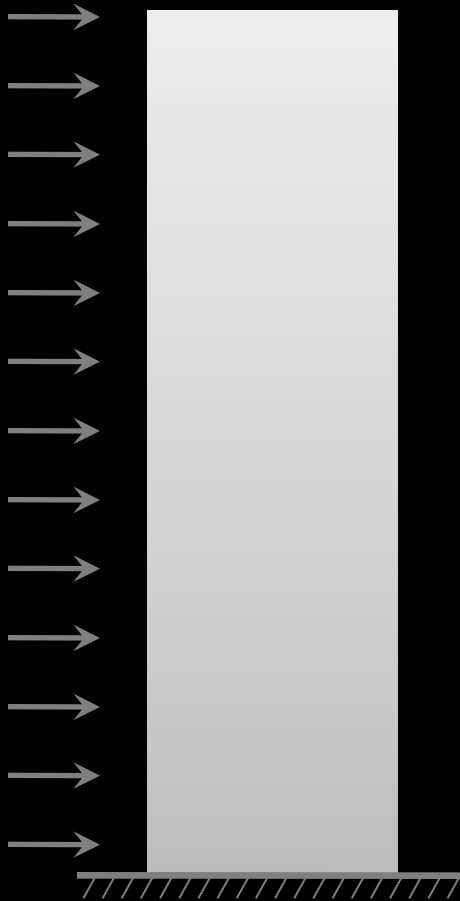


John Hancock Building



Patterns of Different Sizes

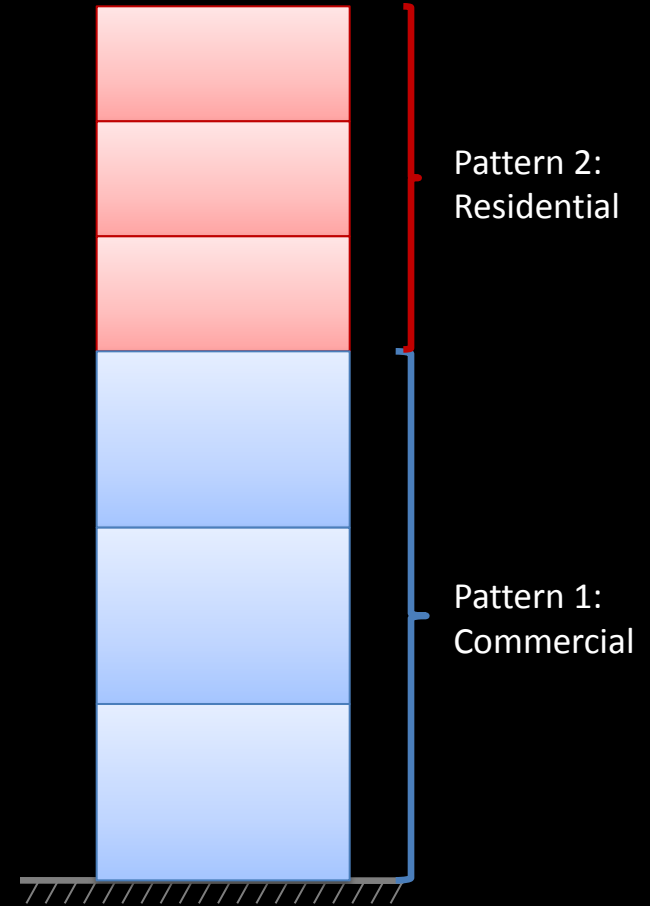
Motivation: Functionally Graded Buildings



Unconstrained Problem



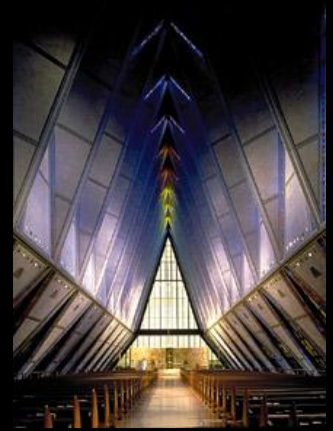
Trump Tower



Groups of Patterns

Outline

- Introduction and Motivation
- Topology Optimization Framework
 - Basic problem formulation
- Manufacturing constraints and pattern gradation
 - Uniform Density approach
 - CAMD approach
 - Projection scheme (length scale)
- Numerical Results
 - 2D
 - Graded thicknesses using Lagrange Multipliers
 - Building example in 3D
- Concluding Remarks



Topology Optimization Framework

- Minimum compliance problem in discrete form:

$$\min_{\rho, \mathbf{u}}: \quad c(\rho, \mathbf{u})$$

Objective function

$$s. t. : \quad \mathbf{K}(\rho)\mathbf{u} = \mathbf{f}$$

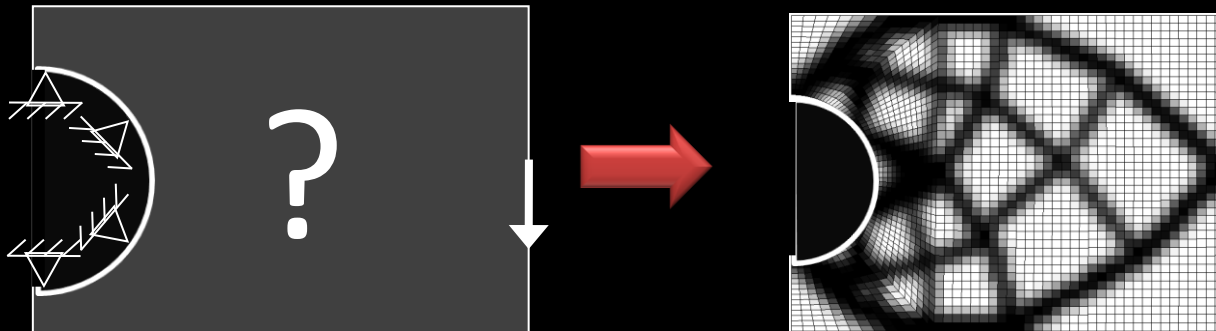
Equilibrium constraint

$$\int_{\Omega} \rho \, dV \leq V_s$$

Volume constraint

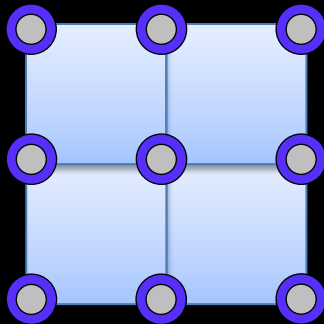
- Solid Isotropic Material with Penalization (SIMP) model:

$$E(\mathbf{x}) = \rho(\mathbf{x})^p E^0, \quad p > 1$$



Manufacturing Constraints and Pattern Gradation

- **Uniform Element Density Approach:** design variables are coincident with element centroids (or nodes)
- **CAMD Approach:** design variables are nodal densities and shape functions used to obtain density throughout design domain



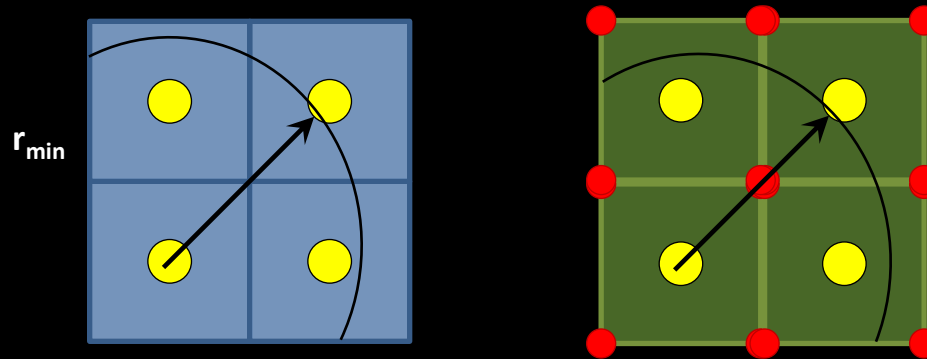
$$\rho(\mathbf{x}) = \sum_{e=1}^n \sum_{i=1}^4 N_i^e(\mathbf{x}) \rho_i^e$$

- **Update sensitivities:**

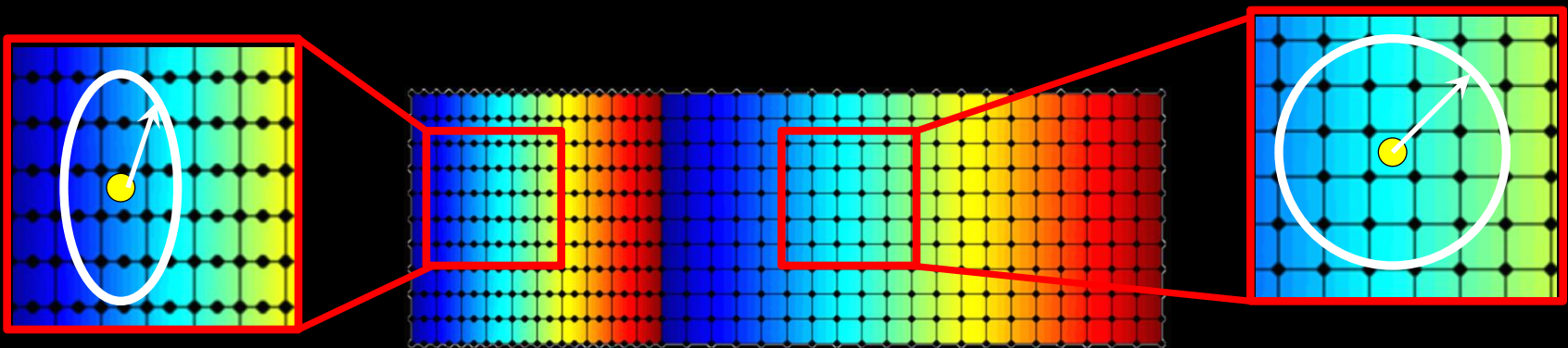
$$\frac{\partial c}{\partial \rho_d} = \sum \frac{\partial c}{\partial \rho_i^e} \frac{\partial \rho_i^e}{\partial \rho_d}$$

Projection scheme with graded patterns

- Projection using element centroids or nodal densities as design variables

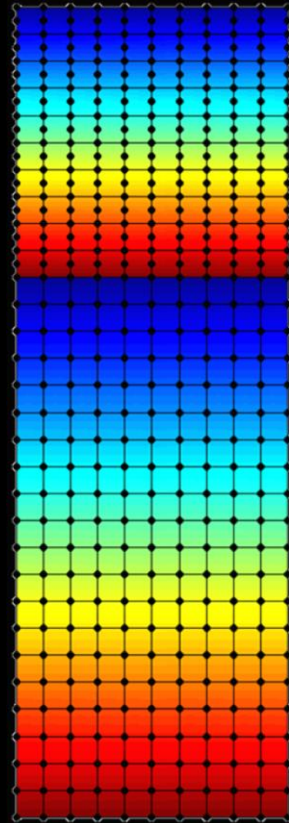
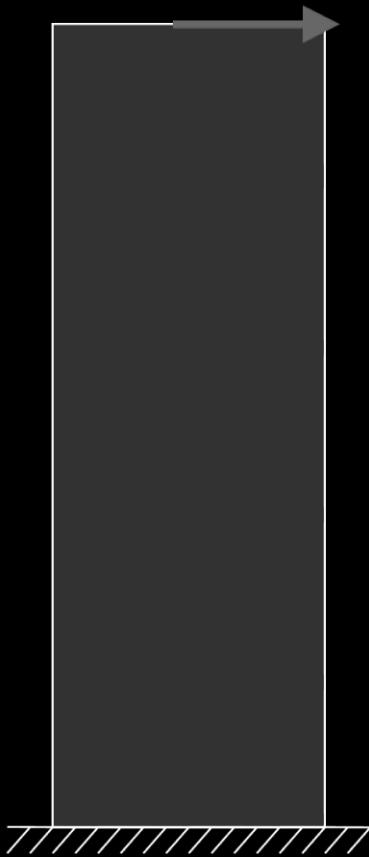


- Must use scaled projection for pattern gradation

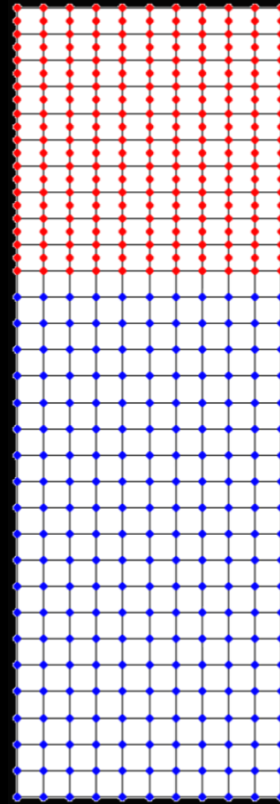


Numerical Examples

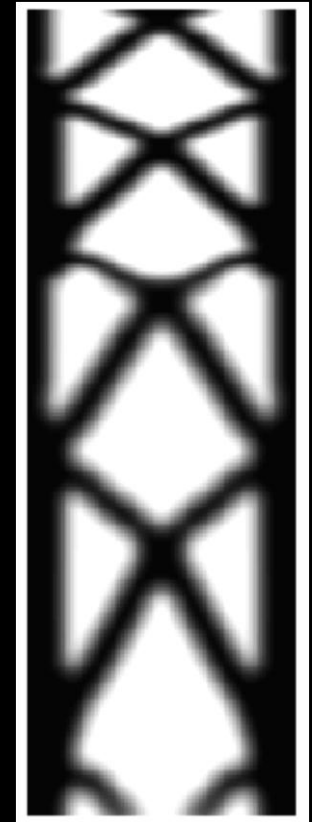
- Graded cantilever building: Uniform Element Densities



Pattern constraints



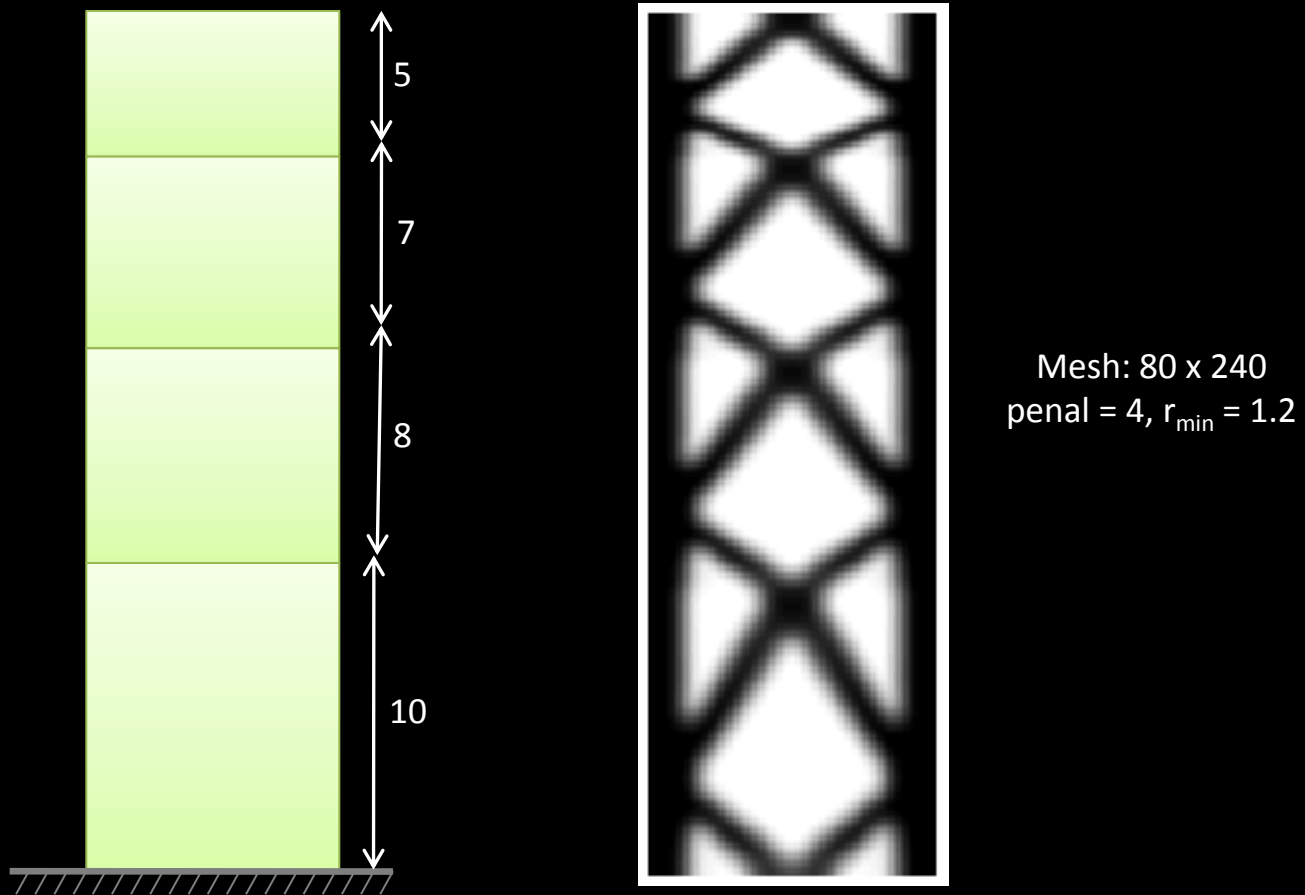
Design variables



Mesh: 80 x 240
penal = 4, $r_{\min} = 1.2$
volume = 50%

Numerical Examples

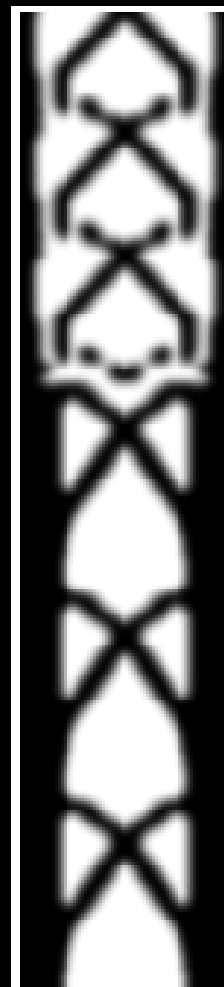
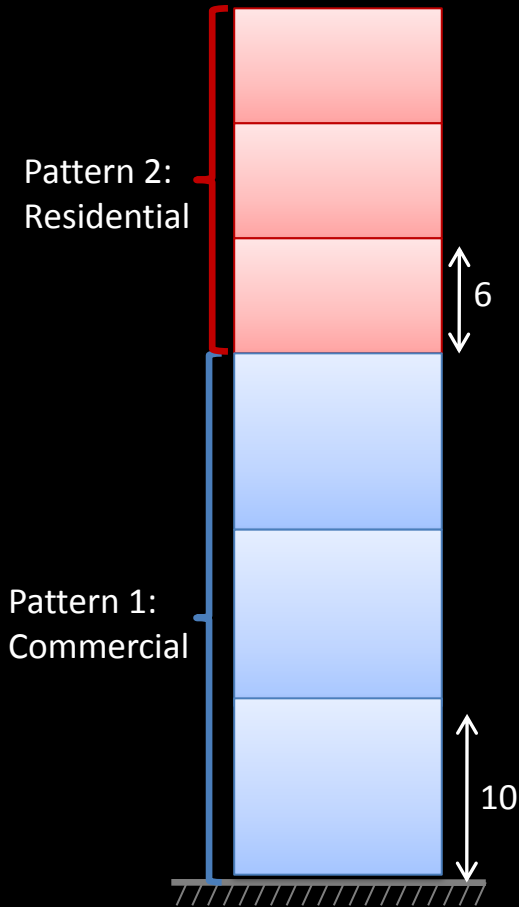
- Patterns of Different Sizes: Uniform Element Densities



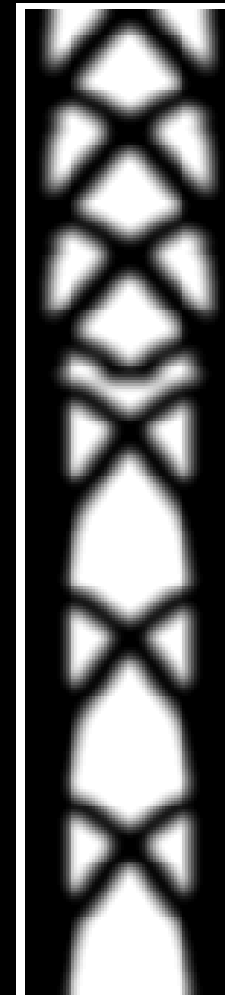
Numerical Examples

Mesh: 75 x 360
penal = 4, $r_{\min} = 1.2$

- Multiuse Building w/ volume gradation



Unconstrained Volume (50%)



With volume constraints

60%

60%

40%

60%

Virtual Work/Lagrange Multipliers for gradation in wall thicknesses

- Virtual Work

$$W_i = \int_A [N^T \delta \eta + M^T \delta \chi + V^T \delta \Gamma] dA$$

axial flexural shear

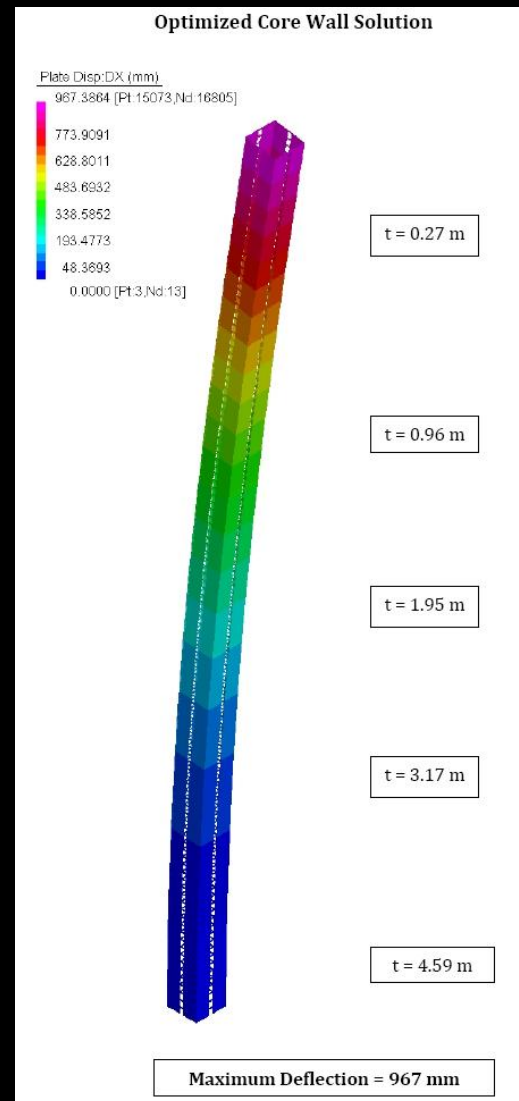
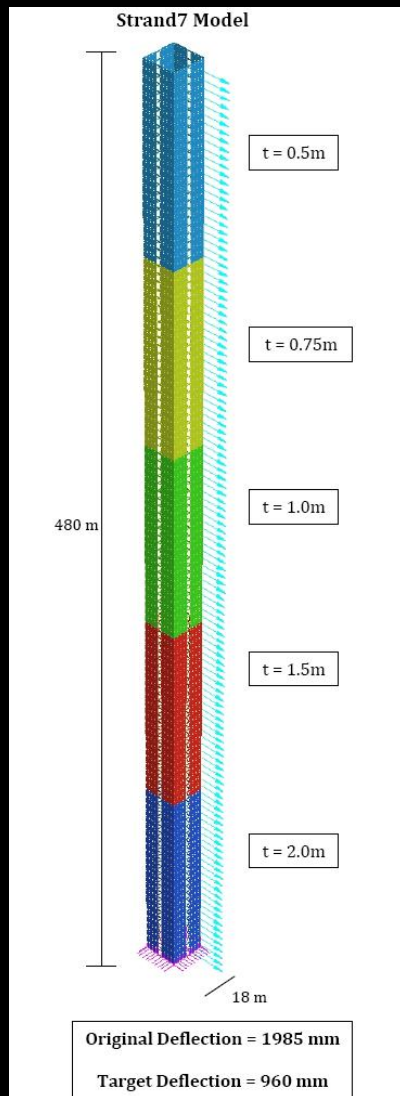
- Lagrange Method

$$\Delta = \sum_{plates} \xi_j + \lambda (\sum t_j A_j - V)$$

- Optimal thickness

$$t_i = \frac{1}{\Delta_{req}} \left(\frac{v_i}{A_i} \right)^{0.5} \sum_j (A_j v_j)^{0.5}$$

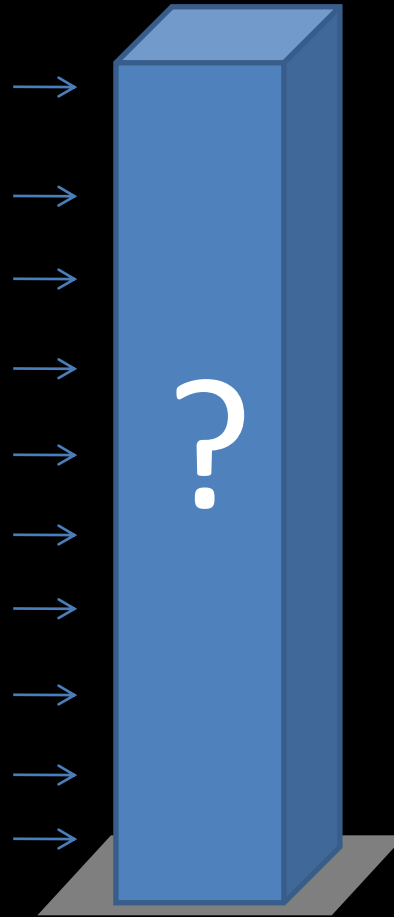
Virtual Work/Lagrange Multipliers for gradation in wall thicknesses



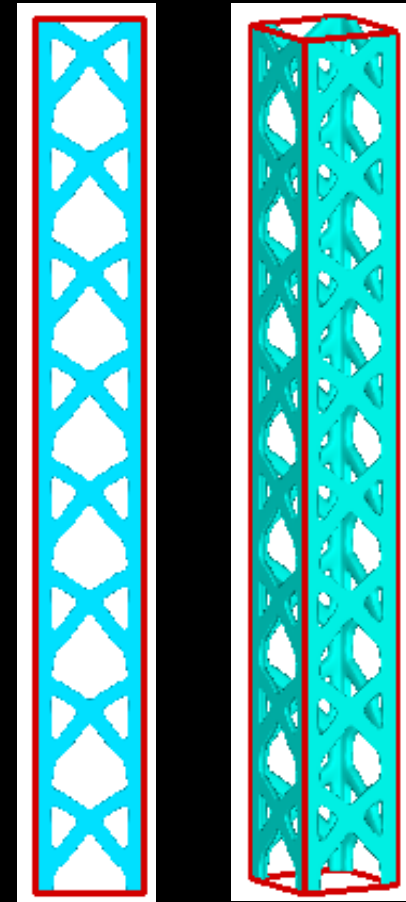
Building Design Example



Skidmore, Owings & Merrill
Proposed Tower Design
Hong Kong



$N = 8$
Mesh: $96 \times 12 \times 12$
Volume = 50%



Proposed Topology Optimization
Design using Pattern Repetition
1,728,000 design variables

Concluding Remarks

- **Manufacturing constraints in topology optimization allow for design of optimal buildings in terms of stiffness, cost, deflection, etc.**
- **Additional building design considerations, such as stability and nonlinear behavior are sources for future investigation**

Concluding Remarks

- **The present approach may be extended for industry purposes by exploring computational expenses associated with non-coincident FEM displacement and design variable meshes to be used on a larger scale**
- **Future work includes optimization of large scale 3D problems using Topological Data Structure (TopS) integrated with finite element analysis and topology optimization**

USNCCM X Presentation

- **C. Talischi, G. Paulino, R. Espinha, A. Pereira, I. Menezes, W. Celes. “Topological embedding using a multilevel mesh representation for topology optimization” Section 63: New Advances in Topology Optimization, July 17, 10:10-10:30.**